In the Claims:

1. (currently amended): Dimer and multimer forms of BAPO compounds of the formula I

wherein

R₁ is unsubstituted or substituted C₁-C₁₂alkyl, benzyl, C₁-C₁₂alkoxy [[,]] or C₃-C₆cycloalkyl er-C₅-C₁₄aryl;

R₂ is unsubstituted or substituted C₃-C₆cycloalkyl or C₅-C₁₄aryl;

Q is a di-tri or tetravalent arylene residue;

n is 1-4, m is 0-2, n+m is 2, 3 or 4.

2. (currently amended): Dimer and multimer forms of MAPO compounds of the formula II

$$\begin{array}{c|c} R_3 & P & Q & P & R_1 \\ \hline R_1 & Q & P & R_1 \\ \hline \end{array}$$

wherein

 R_{4^-} R'_{1} and R_{3} independently of one another are unsubstituted or substituted C_1 - C_{12} alkyl, benzyl, C_{4^-} C_{42} alkexy, C_3 - C_6 cycloalkyl or C_5 - C_{14} aryl;

Q is a di-tri or tetravalent arylene residue;

n is 1-4, m is 0-2, n+m is 2, 3 or 4;

with the proviso, that R_1 R_1 and R_3 are different from each other.

3. (currently amended): Process for the preparation of dimer or multimer forms of BAPO compounds of the formula I according to claim 1 and of dimer or multimer forms of MAPO compounds of the formula II.

characterized in that (n + m) equivalents of a dimetalated-phosphine $R_1P(M)_2$ are reacted with one

to form an intermediate of the formula III

$$\left[\begin{array}{c} M \\ R_1 \end{array}\right]_n Q \left[\begin{array}{c} M \\ P \\ Q \end{array}\right]_m$$

the intermediate III is then reacted either with (n + m) equivalents of a further carboxylic acid halogenide (R₂-CO-HaI) to form dimer or multimer forms of bisacylphosphine-intermediates of the formula IV

or with (n + m) equivalents of a halogenide R₃-Hal to form dimer or multimer forms of monoacylphosphine intermediates of the formula V,

$$\begin{array}{c|c}
R_3 & R_3 \\
\hline
R_1 & R_1 \\
\hline
\end{array}$$

said phosphines IV or V-are then oxidized to form phosphine oxides of the formula I-or II, wherein M is Li, Na or K; and R_1 , R_2 and R_3 ; Q_1 [[;]] n and m are as defined in claim[[s]] 1. and 2.

4. (original): Compounds of the formula III

wherein M, R₁, n and m are as defined in claim 3.

5. (currently amended): Cyclic forms of BAPO compounds of the formula VI-or VII

wherein

- R_4 $R'''_{1,1}$ is unsubstituted or substituted C_1 - C_{12} alkyl, benzyl, C_1 - C_{12} alkoxy, C_3 - C_6 cycloalkyl or C_5 - C_{14} aryl;
- U is a divalent anylene residue and U is a tetravalent anylene residue.
- 6. (currently amended): Process for the preparation of cyclic forms of BAPO compounds of the formula VI

wherein

R"₁ is unsubstituted or substituted C_1 - C_{12} alkyl, benzyl, C_1 - C_{12} alkoxy, C_3 - C_6 cycloalkyl, or C_5 - C_{14} aryl; U is a divalent arylene residue;

characterized in that one equivalent of a dimetalated-phosphine $\mathbf{R}_{\mathbf{1}}\mathbf{P}(\mathbf{M})_{2}$ are is reacted with one equivalent of a <u>dicarboxylic</u> acid halogenide $\mathbf{R}_{\mathbf{1}}\mathbf{P}(\mathbf{M})_{2}$ are is reacted with

to form an intermediate of the formula III'

said intermediate cyclizes and is then oxidized to form phosphine oxides of the formula VI, wherein M is Li, Na or K; R_4 - R_1 and U are as defined in claim 5 above.

7. (currently amended): Process for the preparation of cyclic forms of BAPO compounds of the formula VII

characterized in that two equivalents of a dimetalated-phosphine R₁P(M)₂ R"'₁P(M)₂ is reacted with

one equivalent of a tetracarboxylic acid halogenide

to form an intermediate of the formula III"

said intermediate cyclizes and is then oxidized to form phosphine oxides of the formula VII wherein M is Li, Na or K; $R_4 R'''_{1}$ and U' are as defined in claim 5.

- 8. (currently amended): Process according to any one of claim[[s]] 3, -6 or 7, wherein M is Li and wherein the process is carried out in an inert atmosphere at a temperature from -20 to 80°C.
- 9. (currently amended): Compounds according to any one of claim[[s]] 1, 2 or 4, wherein n is 1 and m is 1.
- 10. (currently amended): Photopolymerizable composition comprising
- (a) at least one ethylenically unsaturated photopolymerizable compound, and
- (b) as photo initiator, at least one compound of the formula I according to claim 1., II, VI or VII as defined above.
- 11. (new): Process for the preparation of dimer or multimer forms of MAPO compounds of the formula II according to claim 2,

characterized in that (n + m) equivalents of a dimetalated-phosphine $R'_1P(M)_2$ are reacted with one

to form an intermediate of the formula III"

$$\begin{bmatrix} R'_1 & P & M & M \\ P & Q & P & R'_1 \end{bmatrix}_m$$

the intermediate III" is then reacted with (n + m) equivalents of a halogenide R_3 -Hal to form dimer or multimer forms of **monoacyl**phosphine intermediates of the formula V,

$$\begin{bmatrix} R_1^3 & R_3 & R_3 \\ R_1^4 & R_1^4 \end{bmatrix}_m = \begin{bmatrix} R_1^3 & R_2^4 \\ R_1^4 & R_2^4 \end{bmatrix}_{V_1}$$

said phosphines V are then oxidized to form phosphine oxides of the formula II according to claim 2, wherein M is Li, Na or K; and R'₁, R₃, Q, n and m are as defined in claim 2.

12. (new): Compounds of the formula III""

wherein M, R'₁, n and m are as defined in claim 11.

- 13. **(new):** Process according to claim 6, wherein M is Li and wherein the process is carried out in an inert atmosphere at a temperature from -20 to 80°C.
- 14. (new): Process according to claim 7, wherein M is Li and wherein the process is carried out in an inert atmosphere at a temperature from -20 to 80°C.
- 15. (new): Process according to claim 11, wherein M is Li and wherein the process is carried out in an inert atmosphere at a temperature from -20 to 80°C.
- 16. (new): Compounds according to claim 2, wherein n is 1 and m is 1.
- 17. (new): Compounds according to claim 4, wherein n is 1 and m is 1.
- 18. (new): Compounds according to claim 12, wherein n is 1 and m is 1.
- 19. (new): Photopolymerizable composition comprising
- (a) at least one ethylenically unsaturated photopolymerizable compound, and
- (b) as photo initiator, at least one compound of the formula II according to claim 2.

- 20. (new): Photopolymerizable composition comprising
- (a) at least one ethylenically unsaturated photopolymerizable compound, and
- (b) as photo initiator, at least one compound of the formula VI according to claim 6.
- 21. (new): Photopolymerizable composition comprising
- (a) at least one ethylenically unsaturated photopolymerizable compound, and
- (b) as photo initiator, at least one compound of the formula VII according to claim 5.

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